



# “ Fundamentals of Thermodynamic Modelling of Materials ”

November 15-19, 2010  
INSTN – CEA Saclay, France

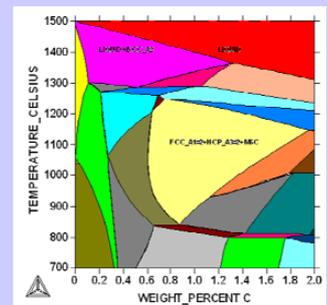
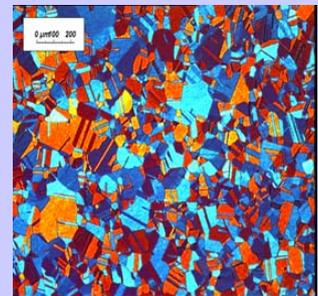
PROFESSOR & TOPIC

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*Multicomponent  
diffusion simulation*

[04002]



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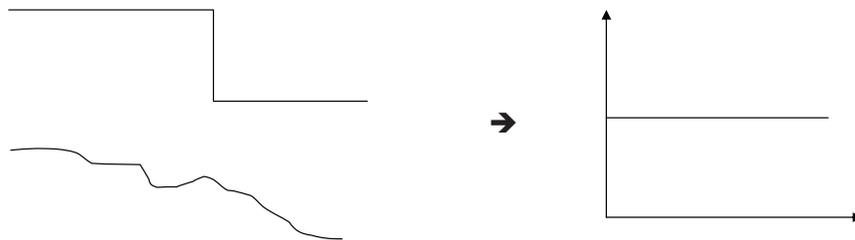
# Multicomponent diffusion

## Basis and application



## Physical basis

- Diffusion from latin "spread out"
- Irreversible process → no such thing as reversed diffusion, i.e. time has a certain direction!



Information is lost, entropy created during diffusion

## Flux and concentration:

Concentration :

Fick's (first) law :

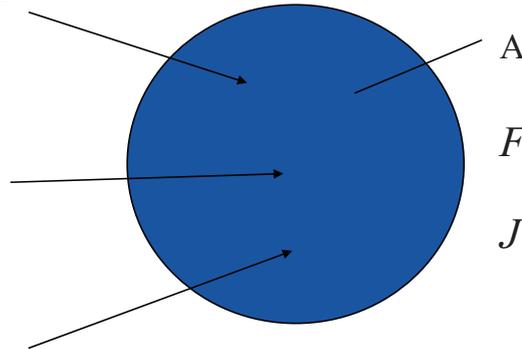
$$J_B = -D_B \frac{\partial c_B}{\partial z}$$

$$c_B = \frac{m_B}{V} = \frac{x_B}{V_m} = \text{mole / volume}$$

or

$$\text{mass}\% * \rho = \text{mass / volume}$$

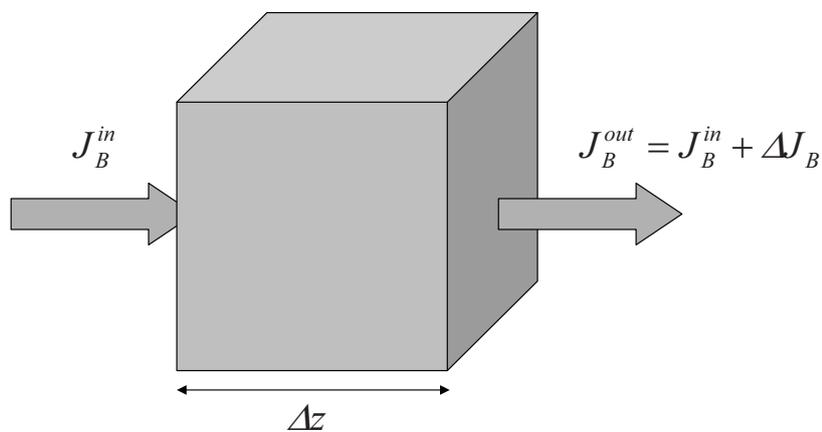
$$\frac{dm_B}{dt}$$



Flux :

$$J_B = \frac{d m_B}{dt} \frac{1}{A}$$

$\frac{dn_B}{dt}$  is not necessarily constant  
consider a planar case



$$\Delta J_B = J_B^{out} - J_B^{in}$$

## Fick's second law

$$\frac{dn_B}{dt} = A(J_B^{in} - J_B^{out}) = -A\Delta J_B$$

$$n_B = c_B \Delta z A$$

$$\frac{dn_B}{dt} = \frac{dc_B}{dt} A \Delta z$$

## Diffusion equations:

Fourier law:  $J_Q = -\lambda \frac{\partial T}{\partial z}$

where  $J_Q$  is the heat flux,  $T$  the temperature and  $\lambda$  the heat conductivity.

Introduce the concentration of enthalpy as  $H_m / V_m$ , where  $H_m$  is the molar enthalpy:

$$J_Q = -D_Q \frac{\partial (H_m / V_m)}{\partial z}$$

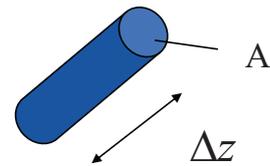
The heat diffusivity:

$$D_Q = \lambda V_m / c_p$$

$c_p = (\partial H_m / \partial T)_p$  is the heat capacity under constant pressure.

Ohm's law

$$I = U / R$$



$I$  is the electric current,  $U$  the voltage and  $R$  the resistance, may be rewritten in a similar form as Fourier's law

$$J_e = -(\Delta z / RA) \frac{\partial u}{\partial z}$$

where  $J_e = I / A$  is the electric charge flux,  $A$  the cross sectional area of the electric conductor and  $\Delta z$  the distance over which the voltage is  $U$ .  $u$  is the electric potential. By introducing the electrical conductivity  $\sigma$  as

$$\sigma = \Delta z / (RA)$$

we have a form completely analogous with Fourier's law.

Introduce chemical potential:

$$\mu_B = f(c_B)$$

$$J_B = -D_B \frac{\partial c_B}{\partial z} = -L_B \frac{\partial \mu_B}{\partial z} = -L_B \frac{d\mu_B}{dc_B} \frac{\partial c_B}{\partial z}$$

$$D_B = L_B \frac{d\mu_B}{dc_B}$$

**Flux is proportional  
to force**

$$v_B = M_B F_B = -M_B \frac{\partial \mu_B}{\partial z}, \quad J_B = c_B v_B$$

$$J_B = -c_B M_B \frac{\partial \mu_B}{\partial z} = -c_B M_B \frac{d\mu_B}{dc_B} \frac{\partial c_B}{\partial z} = -D_B \frac{\partial c_B}{\partial z}$$

$$D_B = c_B M_B \frac{d\mu_B}{dc_B}$$

$$\mu_B = \mu_B^0 + RT \ln a_B = \mu_B^0 + RT \ln f_B + RT \ln c_B$$

$$\frac{d\mu_B}{dc_B} = \frac{RT}{c_B} \left( 1 + \frac{d \ln f_B}{d \ln c_B} \right)$$

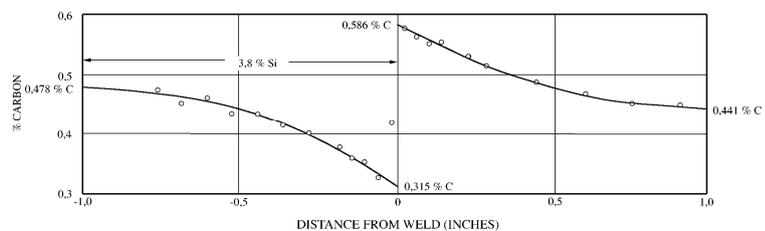
$$D_B = RT M_B \left( 1 + \frac{d \ln f_B}{d \ln c_B} \right)$$

Ternary system A-B-C:  $\mu_B = f(c_B, c_C)$

$$J_B = -M_B c_B \frac{\partial \mu_B}{\partial z} = -M_B c_B \left\{ \frac{\partial \mu_B}{\partial c_B} \frac{\partial c_B}{\partial z} + \frac{\partial \mu_B}{\partial c_C} \frac{\partial c_C}{\partial z} \right\} \Rightarrow$$

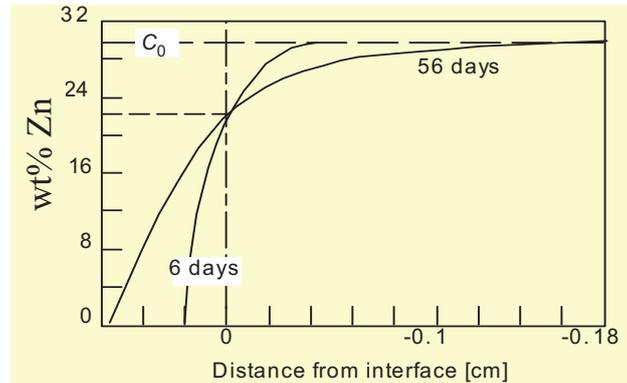
$$J_B = -D_{BB} \frac{\partial c_B}{\partial z} - D_{BC} \frac{\partial c_C}{\partial z}$$

Example:  
Fe-Si-C Darken effect:



# Frames of reference

- We have to measure flux relative something!
- Many choices possible!
- Example: Consider a composite of Cu and Cu-32% Zn:



If we are only interested in the mixing of Cu and Zn we may regard diffusion as if Cu and Zn exchange place:  $J_{Cu} = -J_{Zn}$ .  
We then have:

$$J_{Cu} = -D_{Cu} \frac{\partial c_{Cu}}{\partial z} = -J_{Zn} = -\left( -D_{Zn} \frac{\partial c_{Zn}}{\partial z} \right)$$

$$c_{Cu} + c_{Zn} = \frac{x_{Cu}}{V_m} + \frac{x_{Zn}}{V_m} = \frac{1}{V_m} \cong \text{const} \quad : \quad \frac{\partial c_{Cu}}{\partial z} + \frac{\partial c_{Zn}}{\partial z} \cong 0$$

$$J_{Cu} = -D_{Cu} \frac{\partial c_{Cu}}{\partial z} \quad \text{and} \quad J_{Zn} = D_{Zn} \frac{\partial c_{Cu}}{\partial z}$$

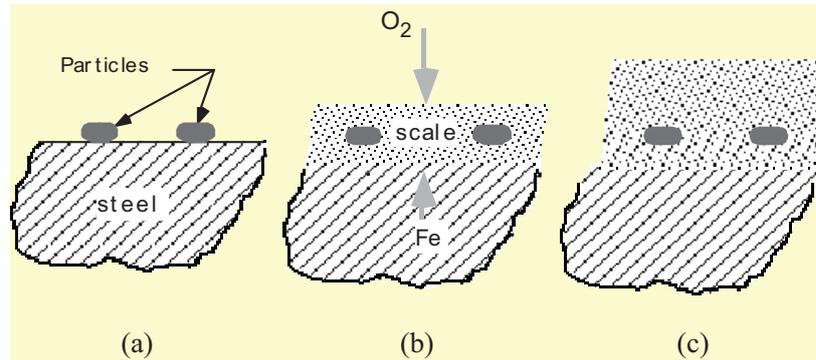
$$\text{If } J_{Cu} = -J_{Zn} \quad : \quad D_{Cu} = D_{Zn} = \tilde{D}_{CuZn}$$

$D$  is called, for example:  
**chemical diffusion coefficient**  
**interdiffusion coefficient.**

The corresponding frame of reference is usually called number fixed frame of reference because there is no net-flow of atoms:

$$J_{Cu} + J_{Zn} = 0$$

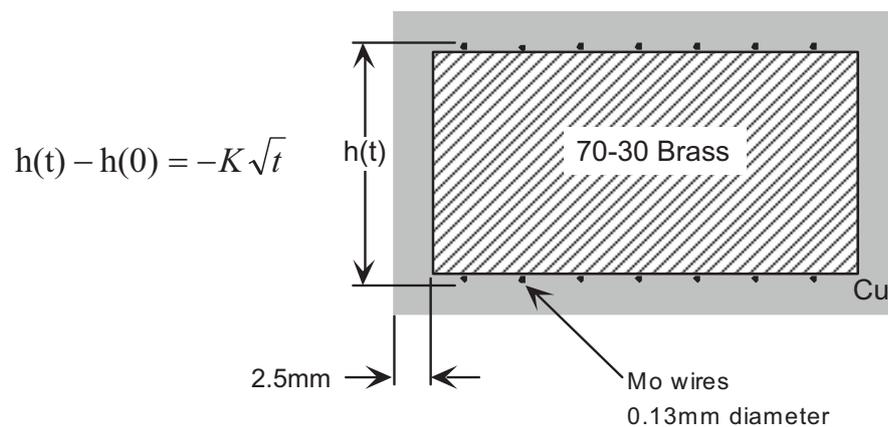
Pfeil's (1929) observations of the diffusion-controlled overgrowth of an oxide scale



It seems as the particles have moved!

## Kirkendall's Diffusion Couple

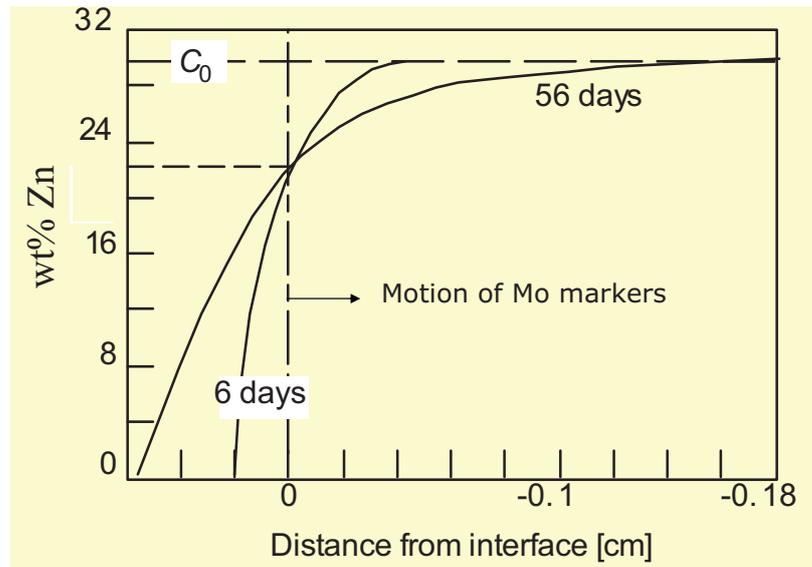
Schematic of the Smigelskas–Kirkendall diffusion couple



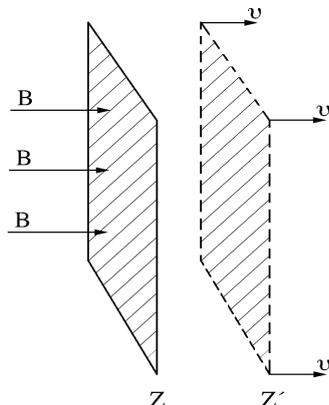
It seems as the Mo-wire has moved!



## Zn concentration profile



If we express the fluxes relative the markers (fixed to the lattice) we may evaluate one flux for Cu and one for Zn and in general  $J'_{Cu} + J'_{Zn} \neq 0$ . This is called the lattice-fixed frame of reference and we denote it with  $J'$ .



We may transform the number-fixed frame by means of:

$$J_{Cu} = J'_{Cu} - x_{Cu} (J'_{Cu} + J'_{Zn})$$

$$J_{Zn} = J'_{Zn} - x_{Zn} (J'_{Cu} + J'_{Zn})$$

---


$$J_{Cu} + J_{Zn} = J'_{Cu} + J'_{Zn} - (J'_{Cu} + J'_{Zn}) = 0$$





## Phenomenological equations

$$J_k^L = -\sum_{i=1}^n L_{ki} \frac{\partial \mu_i}{\partial z} - L_{1T} \frac{\partial T}{\partial z} - L_{1P} \frac{\partial P}{\partial z} - L_{1\phi} \frac{\partial \phi}{\partial z}$$

They are called phenomenological since they stem from no model, but from the observed conditions of equilibrium.

If we choose to consider an isothermal, isobaric and isopotential system we have:

$$J_k^L = -\sum_{i=1}^n L_{ki} \frac{\partial \mu_i}{\partial z} \quad \left( J_k^L = -L_{kk} \frac{\partial \mu_k}{\partial z} \right)$$

## Identification

Assuming that the vacancy exchange mechanism is predominant, and by comparing to the expression derived earlier under this assumption, we may identify:

$$L_{kk} = c_k y_{va} M_{kva}$$

We have now established a relation between M and L.

## Transformation to a volume-fixed frame

$$\begin{aligned}
 J_k &= J_k^L - c_k \mathcal{V} = J_k^L - c_k \sum_{k=1}^n V_k J_k^L \\
 &= -\sum_{i=1}^n L_{ki} \frac{\partial \mu_i}{\partial Z} - c_k \sum_{k=1}^n V_k \sum_{i=1}^n L_{ki} \frac{\partial \mu_i}{\partial Z}
 \end{aligned}$$

or,

$$J_k = -\sum_{i=1}^n L'_{ki} \frac{\partial \mu_i}{\partial Z}$$

where,

$$L'_{ki} = -\sum_{j=1}^n (\delta_{jk} - c_k V_j) L_{ji}$$

## Transformation to concentration gradients

Applying the chain-rule of derivation on the previous equation:

$$J_k = -\sum_{i=1}^n L'_{ki} \frac{\partial \mu_i}{\partial c_j} \frac{\partial c_j}{\partial Z}$$

Or equally if the unreduced diffusivities,  $D_{kj}$  are introduced:

$$J_k = -\sum_{j=1}^n D_{kj} \frac{\partial c_j}{\partial Z}$$

where,

$$D_{kj} = \sum_{i=1}^n L'_{ki} \frac{\partial \mu_i}{\partial c_j}$$



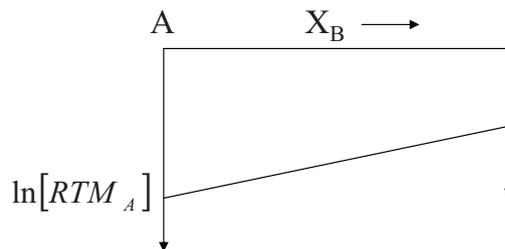


## Modeling of the atomic mobility

When treating the composition dependency of the mobility it has been found superior to expand the logarithm of the mobility rather than the value itself, i.e.

$$RT \ln[RTM_B] = RT \ln M_B^0 - Q_B + RT \ln^{mg} \Gamma$$

Because  $\ln[RTM_i]$  is often found to have a fairly linear composition dependency



## Modeling of the atomic mobility

Both  $RT \ln M_B^0$  and  $-Q_B$  will in general depend upon the composition, the temperature and pressure.

In the spirit of the CALPHAD approach, the composition dependency of these two factors is represented with a linear combination of the values at each end-point of the composition space, and a Redlich-Kister expansion.

$$\Phi_B = \sum_i x_i \Phi_B^i + \sum_i \sum_{j>i} x_i x_j \left[ \sum_{r=0}^m {}^r \Phi_B^{i,j} (x_i - x_j)^r \right]$$

where  $\Phi_B$  represents  $RT \ln M_B^0$  or  $-Q_B$ .

## Modeling of the atomic mobility

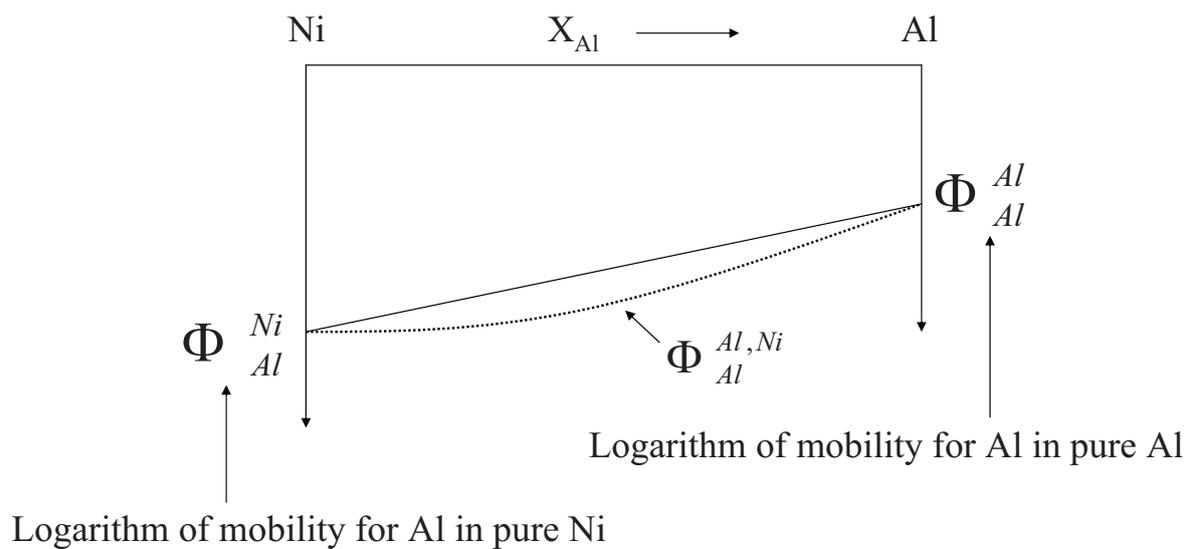
Example: Expression for the mobility of Al in a binary system Ni-Al.

$$RT \ln[RTM_{Al}] = \underbrace{RT \ln M_{Al}^0 - Q_{Al}}_{\Phi_{Al}}$$

Where,

$$\Phi_{Al} = x_{Al} \Phi_{Al}^{Al} + x_{Ni} \Phi_{Al}^{Ni} + x_{Al} x_{Ni} \Phi_{Al}^{Al,Ni}$$

## Modeling of the atomic mobility



## Building a kinetic database

- Collect experimental information

*Different levels of ambition!*

In a database for A-base alloys:

1. Find Tracer or Dilute diffusivities of the elements (B,C,D...) in A. These can be entered directly in the database, assuming that the mobilities are concentration independent.

## Example

Tracer diffusion coefficient of Al and Ni in pure Ni:

$$D_{Ni}^* = 2.26 \cdot 10^{-4} \cdot \exp\left(\frac{-287000}{RT}\right)$$

$$D_{Al}^* = 7.5 \cdot 10^{-4} \cdot \exp\left(\frac{-284000}{RT}\right)$$

The tracer diffusion coefficient is directly related to the mobility:

$$RT \ln(D_i^*) = RT \ln(RTM_i)$$

In the database:

PARAM MQ(FCC\_A1&NI,NI:VA),, -287000+R\*T\*LN(2.26E-4)

PARAM MQ(FCC\_A1&AL,NI:VA),, -284000+R\*T\*LN(7.5E-4)





## Example of data

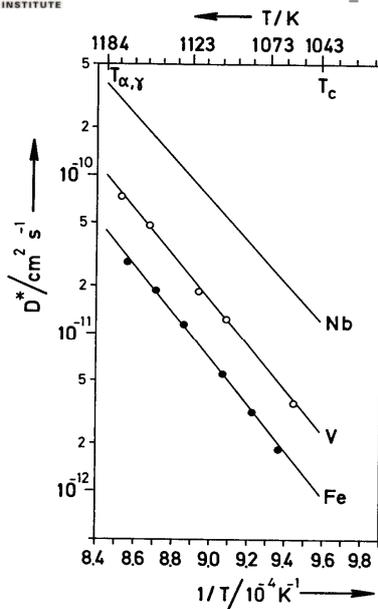


Fig. 2. Arrhenius plots of impurity diffusion of  $^{48}\text{V}$  (○) and self-diffusion (●) in  $\alpha$ -iron. Impurity diffusion of  $^{95}\text{Nb}$  is shown for comparison<sup>20</sup>.

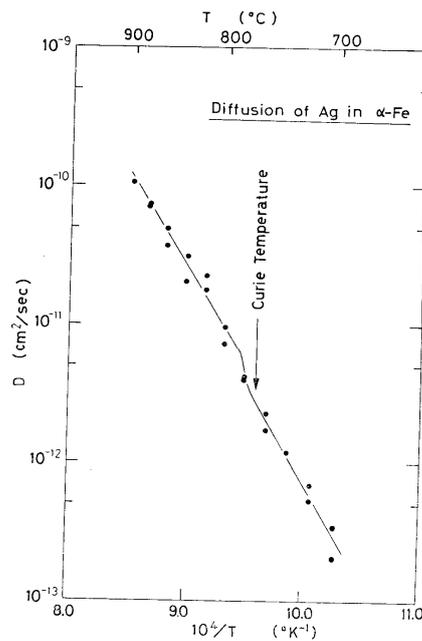


FIG. 5. Temperature dependence of diffusivities of  $\text{Ag}^{110\text{m}}$  in  $\alpha$ -Fe.

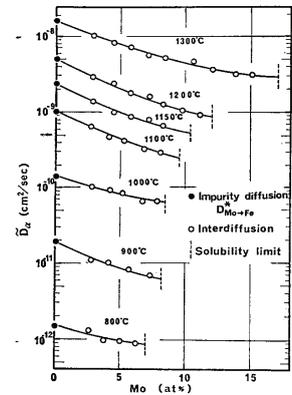


Fig. 3. Concentration dependence of interdiffusion coefficient in  $\alpha$  phase of Fe-Mo system.

## Assessment of data: Binary Ni-Al system

Let us start by considering the Ni-rich side of the system and assume that the mobilities are independent of composition, i.e.

$$\Phi_{Al} = \Phi_{Al}^{Al} = \Phi_{Al}^{Ni}$$

Then we need only two parameters for the database, i.e.

$$\Phi_{Al}^{Ni} \quad \text{and} \quad \Phi_{Ni}^{Ni}$$

### Assessment of data: Binary Ni-Al system

These two parameters we can determine from the tracer diffusion coefficients of Al and Ni in Ni, i.e.

$$\Phi_{Al}^{Ni} = RT \ln D_{Al}^* = -284000 + RT \ln 7.5 \cdot 10^{-4}$$

$$\Phi_{Ni}^{Ni} = RT \ln D_{Ni}^* = -287000 + RT \ln 2.26 \cdot 10^{-4}$$

### Assessment of data: Binary Ni-Al system

Next step to improve the description would be to assume a linear concentration dependence for the mobilities of Al and Ni.

We then need the mobilities in pure Al as well, e.g.

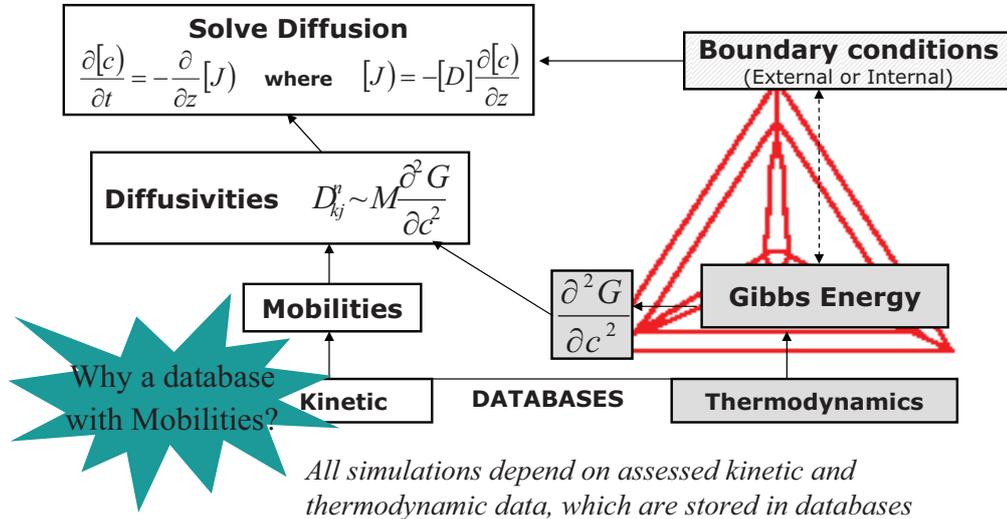
$$\Phi_{Al}^{Al} = RT \ln D_{Al}^* = -142000 + RT \ln 1.71 \cdot 10^{-4}$$

$$\Phi_{Ni}^{Al} = RT \ln D_{Ni}^* = -145900 + RT \ln 4.4 \cdot 10^{-4}$$

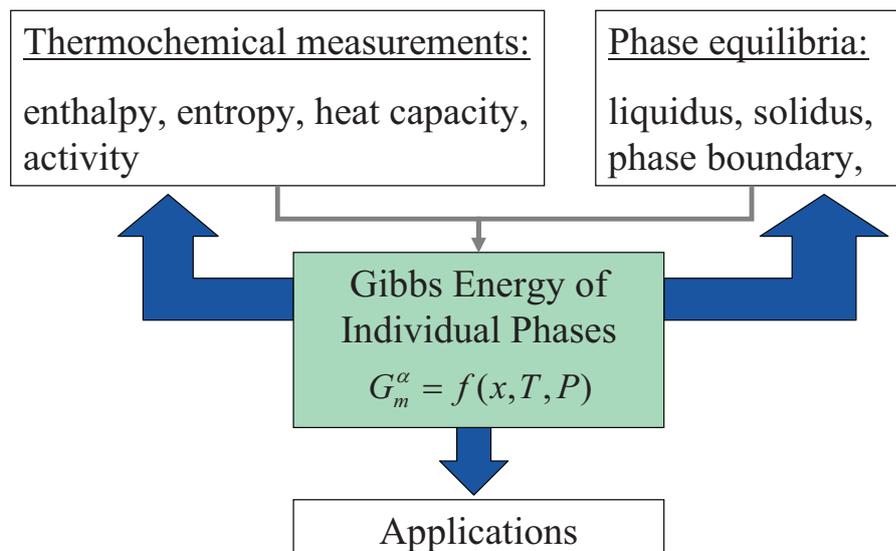


# Basic calculation procedure

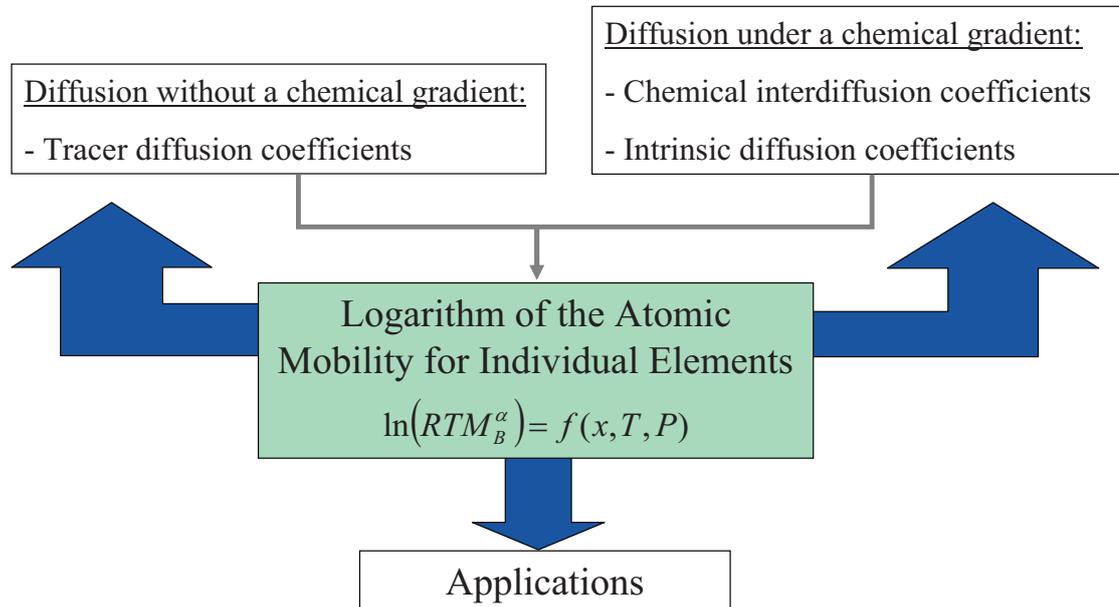
*A numerical finite difference scheme is used for solving a system of coupled parabolic partial differential equations*



# Thermodynamic Databases (The CALPHAD approach)



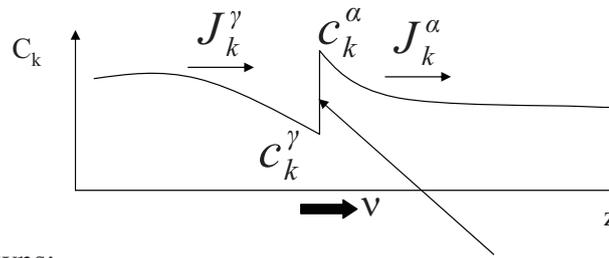
# Kinetic Databases (in a CALPHAD spirit)



## Several application types

- Diffusion in single-phase systems
- Diffusion with moving interfaces (growth, dissolution of particles etc.)
- Cell calculations (particle distributions, immobile interfaces etc.)
- Diffusion in dispersed systems
- Coarsening or Oswald ripening

# Diffusion with a moving interface



n-1 unknowns:

n-2 chemical potentials.

Velocity of phase boundary,  $v$

*Sharp interface with assumption of local equilibrium*

n-1 Flux Balance Equations:

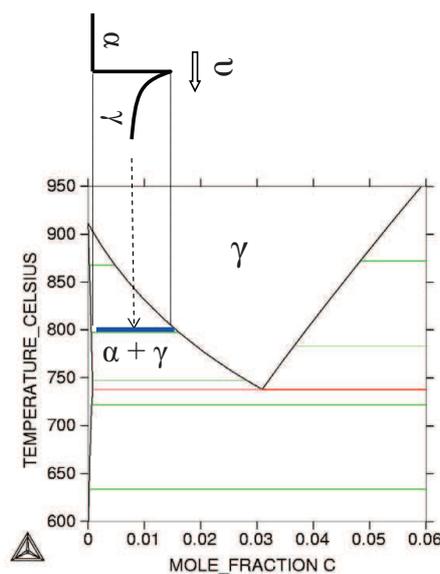
$$v(c_k^\alpha - c_k^\gamma) = J_k^\alpha - J_k^\gamma$$

F-B Equations solved as:

$$\sum_k^{n-1} (v(c_k^\alpha - c_k^\gamma) - (J_k^\alpha - J_k^\gamma))^2 < \epsilon$$

# Diffusion with a moving interface

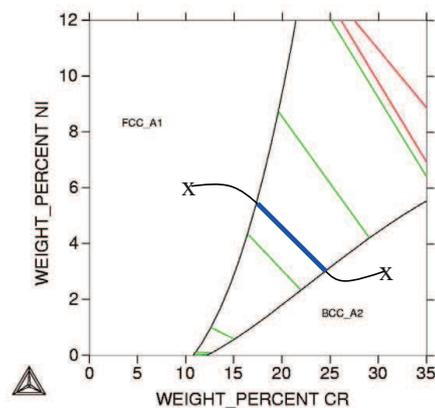
Binary example: Fe-C



Ternary example: Fe-Cr-Ni

$n = 3 \Rightarrow$  two unknowns!

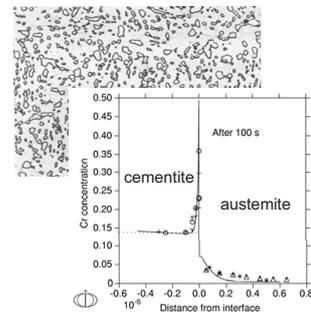
- One  $a_i$  or  $\mu_i$  (i.e. one tie-line)
- The velocity



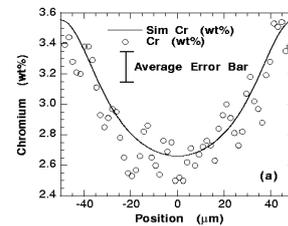
## Some application examples

- $\gamma$  to  $\alpha$  transformations in steel
- Growth or dissolution of carbides
- Microsegregation during solidification
- Nitriding of steels
- Nitrocarburising of steels
- $\sigma$ -phase precipitation in stainless steels
- Transient Liquid-Phase bonding of alloys
- Sintering of cemented carbides
- *and much more ...*

### Carbide dissolution



### Microsegregation during solidification



## Purpose of DICTRA

Have a possibility to Teach, i.e. bring new insight into problems.

...by linking fundamental models to critically assessed thermodynamic and kinetic data.

## Purpose of DICTRA

Provide an engineering tool for materials and process design.

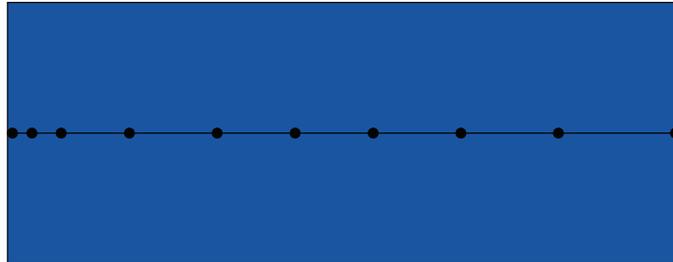
...by allowing simulations to be performed with realistic conditions and data on alloys of practical importance.

## Region



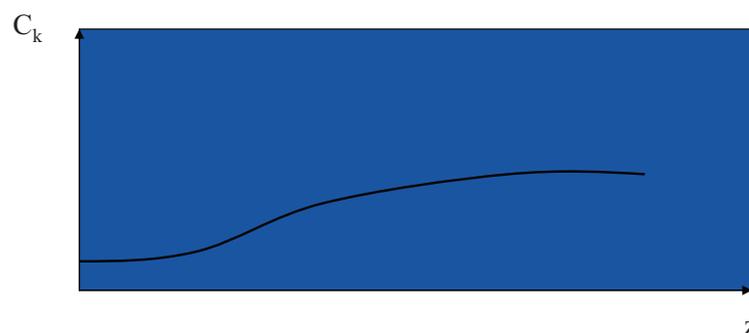
A "box" with an arbitrary name

## Grid



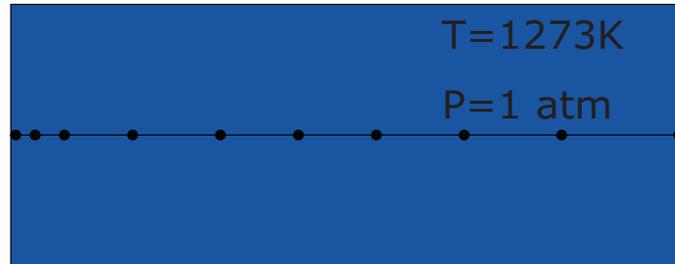
Distribution of node points for numerical calculations

## Concentration Profile



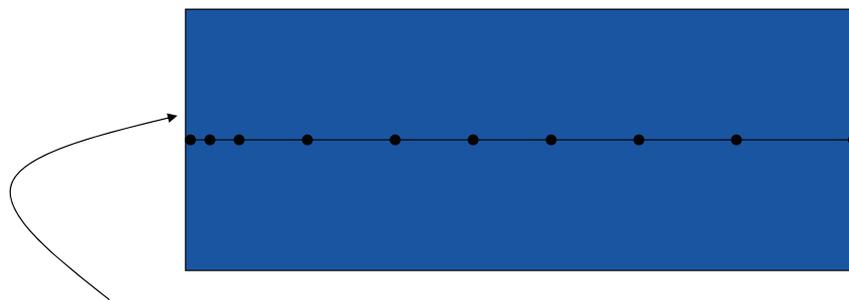
Concentration,  $C_k$  of an element as a function of distance  $z$

## Global Conditions



Conditions valid for entire system, T and P

## Boundary Conditions



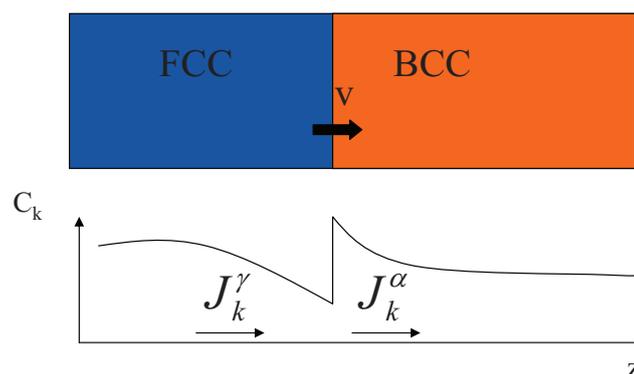
$a_c=1$  (carburization)

Conditions that apply to region boundaries  
(could be functions of time and  
temperature)

# Moving Phase Boundary Calculations

- Used for calculating growth or dissolution of a phase.
- Assumptions:
  - Local equilibrium holds at the phase boundary, i.e. concentrations at the boundary can be calculated from an equilibrium calculation in T-C.
  - Diffusion controls the movement of the phase boundary
- Application examples:
  - ✓ Carbide dissolution
  - ✓ Solidification
  - ✓ Growth of  $\sigma$ -phase in a stainless steel

## Moving phase boundary simulation



Solve diffusion equation in each phase

Calculate displacement of phase boundary

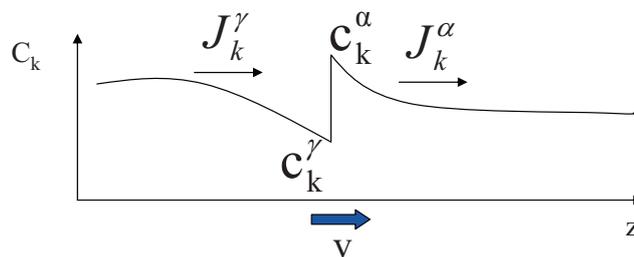
Use Thermo-Calc to find tie-lines

## M-P-B theory

Unknowns: Tie-line, specified by  $n-2$   $a_i$  or  $\mu_i$   
 Velocity of phase boundary,  $v$

Equations:  $n-1$  flux-balance equations,  $v(c_k^\alpha - c_k^\gamma) = J_k^\alpha - J_k^\gamma$

Solved as:  $v(c_k^\alpha - c_k^\gamma) - (J_k^\alpha - J_k^\gamma) = 0$



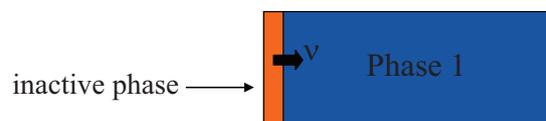
## Moving Phase Boundary

- Moving phase boundaries simulations may be setup in DICTRA in two different ways:

- Introducing two or more adjacent regions containing different phases



- Entering an inactive phase (formed when thermodynamically stable)



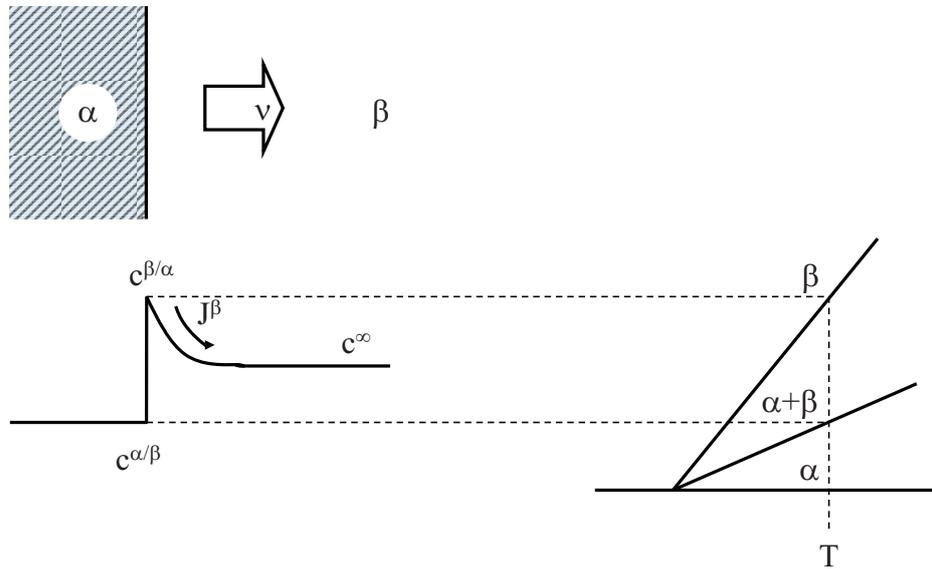
## Assumptions – Sharp interface model

- local equilibrium
- profiles as piecewise linear functions
- volume is independent of composition
- volume fixed frame of reference

## Calculation scheme - binary case

- determine tieline
- solve PDE
- solve flux balance equation
- update grid

# LE – Tieline in Binary system



PDE

$$\frac{\partial \mathbf{c}_k}{\partial t} = \frac{\partial}{\partial z} \left( \mathbf{D}_k \frac{\partial \mathbf{c}_k}{\partial z} \right)$$

Solved by FDM / FEM

## Flux balance equation

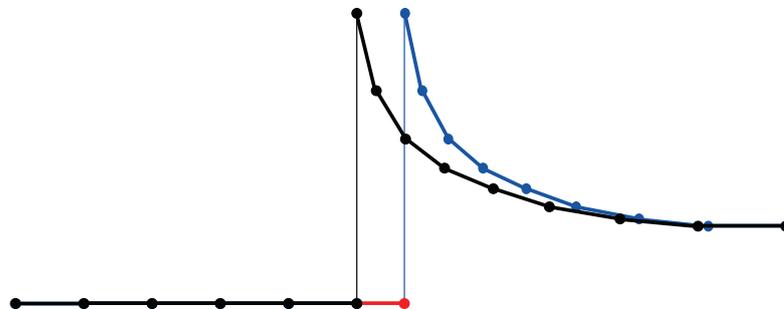
$$v^\alpha c_k^\alpha - v^\beta c_k^\beta = J_k^\alpha - J_k^\beta \quad k=1,2,\dots,n-1$$

$c_k^\alpha, c_k^\beta$  from LE

$J_k^\alpha, J_k^\beta$  from PDE (and LE)

$$\Rightarrow v^p(v^\alpha, v^\beta)$$

## Grid update



## u-fraction

- mole fraction:

$$x_k = \frac{N_k}{\sum_i N_i}$$

- mass fraction:

$$w_k = \frac{N_k m_k}{\sum_i N_i m_i}$$

- u-fraction:

$$u_k = \frac{N_k}{\sum_{i \in S} N_i}$$

## Calculation scheme - multicomponent case

- fix activities/potentials
- determine tieline
- solve PDE
- solve flux balance equations
- guess new activities/potentials until
  - flux balance equations are fulfilled
- update grid

# LE in ternary systems

